

MICROSTRUCTURED SENSOR

The present invention relates to a microstructured sensor that can be in particular a gas sensor or acceleration sensor, and a method for its manufacture.

Some sensors have, in addition to a measurement channel, a  
5 reference channel for carrying out two measurements in parallel or that are carried out under different conditions. In gas sensors having a reference channel, two separate chips, generally of different wafers, are mounted in a housing. Such gas sensors generally have a membrane having an undercut  
10 cavity. However, the internal pressure of the sensor, or the cavity internal pressure, as well as additional parameters such as doping and cavity depth, can deviate significantly from one another in the different sensors, so that different measurement characteristics, and therefore high degrees of  
15 imprecision, can result in the comparison of the measurements of gas sensors. Also, the manufacturing of two sensors and their placement in a housing result in correspondingly high manufacturing costs.

In addition, acceleration sensors are known in which to  
20 measurement structures operated in parallel are formed on one chip. The contacting takes place through contact pads or outer terminals on one side of the chip. Given a more expensive connection of the sensor in a housing, the contacting to the conductive frame or lead frame of the housing may be  
25 expensive.

In contrast, the sensor according to the present invention, and the method according to the present invention for its manufacture, has in particular the advantage that a high

degree of spatial integration of to measurement structures is possible. According to the present invention, both measurement structures are formed on one chip and are accommodated in a common intermediate space under a cap. Very good

5   synchronization characteristics are achieved through the spatial proximity, the identical gas content, and in particular also the identical internal pressure, as well as the direct thermal coupling via the cap and substrate of the measurement chip.

10   Here, a multi-sided situation of the contact areas advantageously enables a better use of the contact pins of the packing housing. In principle, according to the present invention for example a one-sided formation of a larger contact area is also possible, which for example would have to  
15   be contacted to three sides.

The sensor according to the present invention can be in particular a gas sensor that detects infrared radiation in a measurement wavelength range and a reference wavelength range. Through the absorption of infrared radiation in particular  
20   wavelength range is, the concentration of individual gases in a gas mixture, e.g. of CO<sub>2</sub> in the ambient air, can be determined. Such a gas sensor can be used for example to determine the air quality in the passenger compartment of a passenger vehicle, as well as to determine leakages in a  
25   climate control system that uses CO<sub>2</sub> coolant. In addition, selective gas measurements for other gases and applications are also possible. The sensor according to the present invention has at least to measurement areas formed on a chip that are situated in a common intermediate space under a  
30   common cap chip. In principle, it is also possible for more than to measurement areas to be provided. The measurement conditions are very well matched due to the direct thermal coupling between the measurement areas via the substrate and

the common cap, as well as by the identical gas content in the intermediate space.

The design according to the present invention, having two measurement areas on one chip and only one cap, also offers  
5 cost advantages during manufacture in comparison with the separate manufacture of two sensors. In addition, only one chip need be placed and contacted in a sensor module.

In the placement in a housing, both a chip-on-chip and also a flip-chip technique can be used, in which the measurement chip  
10 is placed on an evaluation chip. Here a high degree of efficiency in the use of space can be ensured, because the external terminals can be distributed uniformly, so that the wiring expense on the evaluation chip is lower.

In larger sensors in particular, a way for bonding support  
15 point can be formed in the intermediate space between the two measurement areas, so that the gas sensor can be exposed to high loads. Thus, the sensor can in particular also subsequently be housed in a molded housing without being deformed by the pressures that occur during molding.

20 In the following, the present invention is explained on the basis of the accompanying drawings, showing some specific embodiments.

Figure 1 shows a top view of a chip system of a gas sensor according to a first specific  
25 embodiment, having measurement areas rotated by 180° to one another and having contact areas on two sides;

Figure 2 shows a top view of a gas sensor according to another specific embodiment, having, in  
30 contrast to Figure 1, an additional wafer

bonding support point in the center of the chips;

Figure 3 shows a top view of a chip system of a sensor having contact areas on two opposing sides and having an interrupted centrally situated wafer bonding support point;

Figure 4a shows a top view of a chip system of a gas sensor according to another specific embodiment, having contact areas on two opposite sides and having auxiliary structures for the cap processing at the edge of the chip;

Figure 4b shows a top view of a chip system of a gas sensor according to another specific embodiment, having a large contact area on one side, a wafer bonding support point as an optical separation, and a common cap recess;

Figure 5 shows a top view of a chip system of a gas sensor according to another specific embodiment having measurement areas situated opposite one another, contact areas on for sides, and auxiliary structures for cap processing on the edge of the chip;

Figure 6 shows a section through an exemplary measurement structure;

Figure 7 shows a vertical section through a sensor module according to a specific embodiment of the present invention, having a sensor placed on an evaluation chip in a molded housing;

Figure 8 shows a vertical section through a sensor module according to another specific

embodiment, having a gas sensor that is contacted with a lead frame and is molded into a housing.

According to Figure 1, a gas sensor 1 has a measurement chip 2 made of silicon and a cap chip 4 that is made of silicon and is fastened on measurement chip 2 in a connection area 3. Between cap chip 4 and measurement chip 2, according to the vertical section seen in Figure 6 an intermediate space 5 is formed that is sealed in vacuum-type fashion against the external space by connecting area 3 between measurement chip 2 and cap chip 4. Connecting area 3 can in particular be formed by a sealing glass connection, having for example a lead glass with a low melting point.

On measurement chip 2, two measurement areas 6, 7 are formed in a lateral direction Y so as to be offset from one another, e.g. directly adjoining one another; in this specific embodiment these measurement areas are also offset somewhat to one another in a longitudinal direction X that runs orthogonal to the lateral direction Y. measurement areas 6, 7 can in particular be formed for the measurement of infrared radiation in various wavelength range is, or for the measurement of accelerations, e.g., an identical acceleration in a first measurement and in a second measurement acting as a reference.

According to the specific embodiment as an infrared sensor or gas sensor according to Figure 6, each measurement area 6 or 7 is formed through microstructuring of measurement chip 2, and has in a known manner, according to Figure 6, a membrane 10 undercut through a cavity 9, a thermal pile structure 12 formed on membrane 10 and made up of two contacted (e.g. overlapping) printed conductors made of differently conductive materials, e.g. a metal and polysilicon, as well as an absorber layer 14 applied on thermal pile structure 12.

Cap chip 4 has on its underside an etched recess 11 for the forming of intermediate space 5. On cap chip 4, above measurement areas 6, 7 radiation filters can be attached using glue that allow infrared radiation S to pass only in predetermined wavelength range is; alternatively, such radiation filters can also be provided at different locations in the optical beam path.

In each of measurement areas 6, 7 infrared radiation S that is to be detected exits through cap chip 4, which is made of silicon that is transparent to the infrared radiation S, and through intermediate space 5, and comes into contact with absorber layer 14, which is heated thereby dependent on the intensity of the radiation. In this way, a thermovoltage is produced at thermopile structure 12 that can be read out electrically. For this purpose, printed conductors 19 run from thermopile structure 12 of measurement areas 6, 7 to contact areas 20, 22, which are subsequent in longitudinal direction X and which have terminal pads 21, 23 for contacting gas sensor 1.

The radiation filters provided in the optical beam path allowed infrared radiation to pass in predetermined different wavelength ranges in order to enable a quantitative measurement of the composition of a gas. Through the reference measurement of second measurement area 7, the measurement of first measurement area 6 can be normed or corrected.

Contact areas 20, 22 of measurement chip 2 are not covered by cap chips 4, and can thus be contacted with wire bonds.

In the specific embodiment of Figure 1, contact areas 20, 22 are offset to one another in the lateral direction Y, and are provided at sides situated opposite one another in longitudinal direction X; i.e., measurement areas 6, 7 and contact areas 20, 22 are rotated to one another by 180° about

a central point of symmetry P, or are situated symmetrically in relation to this point.

The specific embodiment of Figure 2 differs from that of Figure 1 in particular in that in the center of measurement  
5 chip 2 a wafer bond support point 24 is formed on which cap chip 4 is supported on measurement chip 2. For this purpose, cap chip 4 can have for example a web protruding downward; that is, no recess 11 is formed in cap chip 4 in the area of wafer bond support point 24. Wafer bond support point 24 can  
10 for example be formed by a sealing glass connection, corresponding to that of connecting area 3. The additional wafer bond support point 24 increases the stability of gas sensor 1 against loads from above.

In the specific embodiment of Figure 3, measurement areas 6, 7  
15 are situated adjacent to one another in the lateral direction Y. Contact areas 20, 22 are situated on sides of measurement chip 2 situated opposite one another in the lateral direction, and are again recessed from cap chip 4. In this specific embodiment, auxiliary structures 25 for the cap processing are  
20 formed before and after contact areas 20, 22 in longitudinal direction X, as parts of connecting area 3; the same holds correspondingly in Figures 4a and 5. In the specific embodiment of Figure 3, in the center of measurement chip 2 an interrupted wafer bond support point 26 is formed between  
25 measurement areas 6, 7 in order to increase the stability of gas sensor 1. Wafer bond support points 24, 26 of Figures 2, 3 do not, however, partition the entire intermediate space 5 of measurement areas 6, 7, so that a gas exchange is still possible. In the specific embodiment of Figure 4a, in contrast  
30 to that of Figure 3, interrupted wafer bond support point 26 is omitted, but wafer bond support points are possible here as well.

Figure 4b shows a specific embodiment in which measurement areas 6 and 7 are offset in the lateral direction and a wafer bond support point 24 acts as an optical separation. A contact area 29 is left open by cap chip 4 on only one side of measurement chip 2. Contact area 29 can here also be partitioned.

Figure 5 shows a specific embodiment of gas sensor 1 in which a contact area 30, 31 is also provided on each of the two additional outer edges situated opposite one another in the longitudinal direction and is recessed from cap chip 4. In this way, measurement chip 2 can be contacted on all four sides. In this specific embodiment as well, the auxiliary structures 25 described in relation to Figures 3, 4a are formed as parts of connecting area 3 for the cap processing in the isolation of the individual gas sensors 1.

Measurement areas 6, 7 of the specific embodiment of Figures 1 to 5 correspond in their design to the representation shown in Figure 6.

The manufacture of gas sensors 1 of Figures 1 to 5 can take place on the wafer plane before the separation, and is thus economical on a large scale. For this purpose, first measurement areas 6, 7 are structured on a measurement wafer in a known manner. In addition, on a cap wafer a structuring is carried out in order to form the later cap chip 4, in which contact areas 20, 22 are recessed by etching and recesses 11 are formed in the lower side for intermediate spaces 5. Subsequently, the measurement wafer and the cap wafer are fitted to one another and, by means of sealing glass, connecting areas 3, as well as possible wafer bond support points 24, 26, are formed. Subsequently, gas sensors 1 can be manufactured by separation, i.e., sawing of the formed wafer stack.



Gas sensor 1 according to the present invention can be housed in various types of packings. In Figures 7, 8, sensor modules 32, 33 having molded housings are shown as possible specific embodiments. Alternatively, however, it is in principle also possible to use e.g. a pre-molded housing to which a cover is fitted, or a ceramic housing.

In sensor module 32 of Figure 7, gas sensor 1 is placed on an ASIC (application specified integrated circuit) 34, e.g. by gluing using an adhesive later 35, or by soldering. Terminal pads 21 of gas sensor 1 are contacted to ASIC 34 via wire bonds 36. ASIC 34 is in turn placed on a diepad 39. In addition, a lead frame 40 having individual contact pins is provided that is contacted with ASIC 34 via wire bonds 36. This system is molded or injected into a housing 42 made of plastic or of a molding compound. For the manufacturing, for example each gas sensor 1 can be placed on an ASIC 34 and can be contacted to it via wire bonds 36. ASICs 34 are subsequently placed onto diepads 39 of a lead frame structure made up of a plurality of contiguous lead frames 40; housing 42 is subsequently molded, and the individual sensor modules 32 are then separated by cutting the lead frame structure.

In the specific embodiment of Figure 8, gas sensor 1 is fastened directly to a diepad 39 for example by means of an adhesive layer 35. Terminal pads 21 of gas sensor 1 are contacted to lead frame 40 via wire bonds, and this system is molded into a housing 42 made of molding compound or plastic.

In the specific embodiment of Figure 7, 8, an evaluation of the measurement signals of gas sensor 1 can be carried out directly in ASIC 34. In principle, however, it is also possible to form an integrated circuit in measurement chip 2 for the evaluation of the measurement signals.